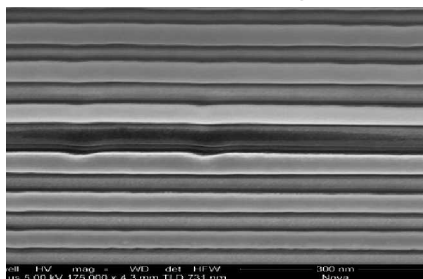


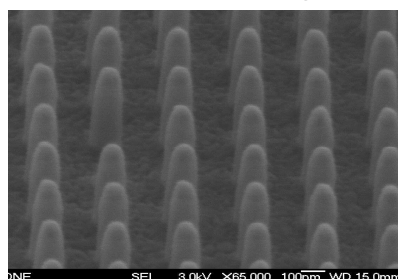
Enhanced Spontaneous Emission Using Visible 3D Logpile Photonic Crystal Structures

Arthur J. Fischer, Ganesh Subramania, Yun-Ju Lee, Qiming Li,
George T. Wang, Daniel D. Koleske

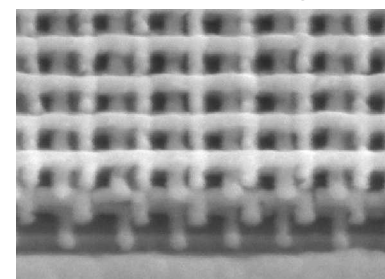
1D Photonic crystal



2D Photonic crystal



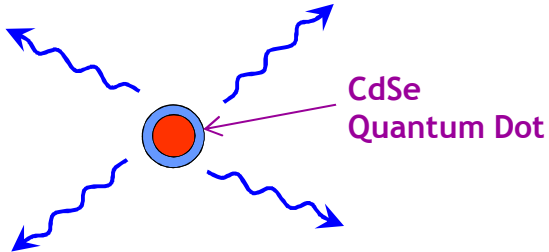
3D Photonic crystal



Work at Sandia National Laboratories was supported by Sandia's Solid-State-Lighting Science Energy Frontier Research Center, funded by the U.S. Department of Energy, Office of Basic Energy Sciences. Sandia National Laboratories is a multi-program laboratory operated by Sandia Corporation, a wholly owned subsidiary of Lockheed Martin company, for the U.S. Department of Energy's National Nuclear Security Administration under contract DE-AC04-94AL85000.

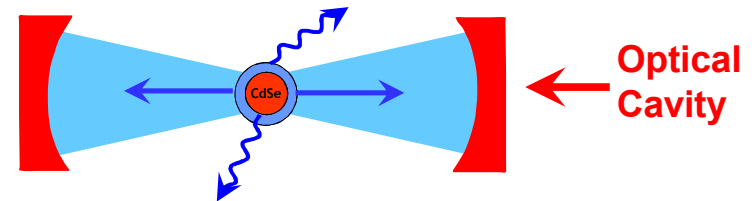
Photonic Density of States and Light Emission

Emitter in free space



- Emitter couples to free space radiation modes
- Emitter decays with natural, fixed radiative rate (R_r)

Emitter in environment with altered photonic density of states



- Emitter couples to different radiation modes
- Radiative rate can be increased or decreased
- Photonic crystals, surface plasmons, etc...

Fermi's Golden Rule:

$$\lambda_{if} = \frac{2\pi}{\hbar} |M_{if}|^2 \rho_f$$

Transition Probability $\nearrow$ λ_{if} $\nwarrow$ Matrix Element $\nearrow$ M_{if} $\nwarrow$ Density of Final States ρ_f

Purcell Effect:

$$F = \frac{3Q_m g(\lambda / 2n)^3}{2\pi V_{eff}}$$

n = index
 g = degeneracy
 λ = wavelength
 Q = quality factor
 V = mode volume

Ultimate control over when and if a photon is emitted !

Light Control In Nature using Photonic Crystals

Morpho butterfly wings



(*M. menelaus*)

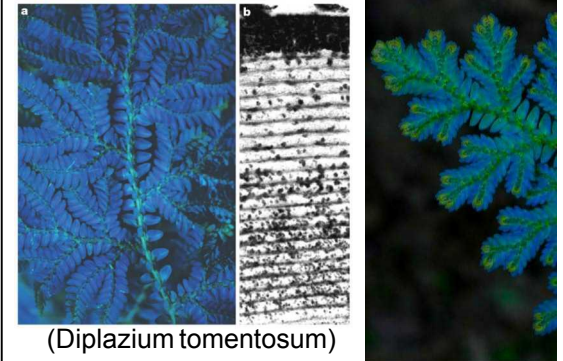
(*M. sulkowskyi*)

R.A. Potyrailo et. al. , Nature Photonics **1**, 123 (2007)

Opal stones



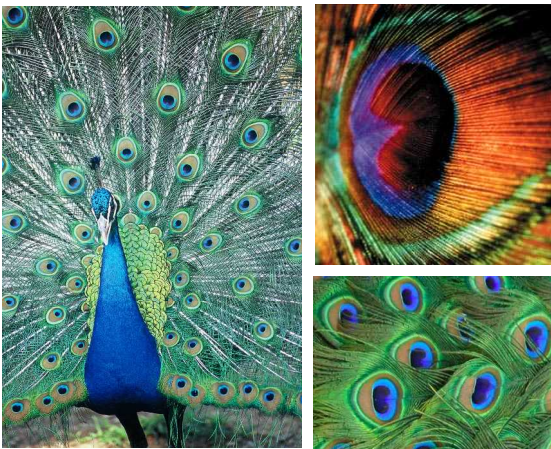
Fern leaves



(*Diplazium tomentosum*)

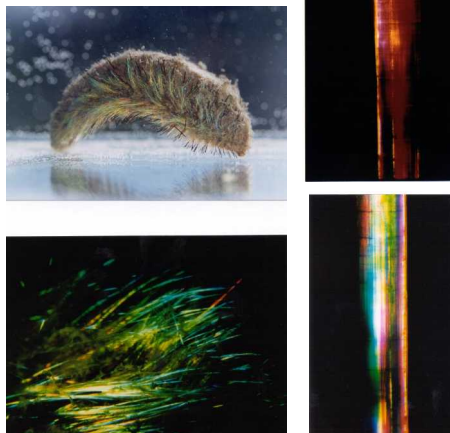
P. Vukusic et. al. , Nature **424**, 852 (2003)

Peacock feathers



Y. Li et al., Phys. Rev. E **72**, 010902 (2005)

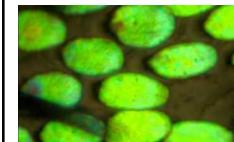
Sea mouse fur



Dr. G. Rouse, School of Biological Sciences
University of Sydney

Beetles

(*Chrysochroa vittata*)



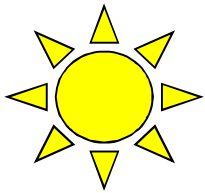
(*Lamprocyphus augustus*)

M.H. Bartl, Department of Chemistry, University of Utah

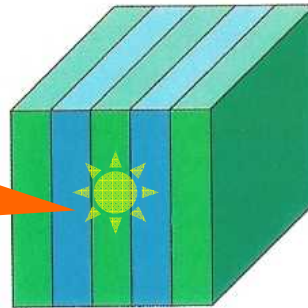
Light emission control with photonic crystals

Photonic Crystal Nanostructures

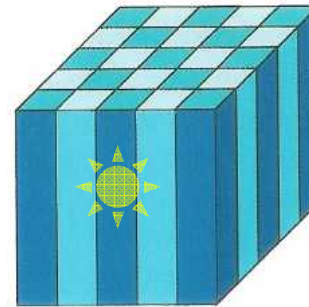
Light Sources
(QDs, Qwires, thermal)



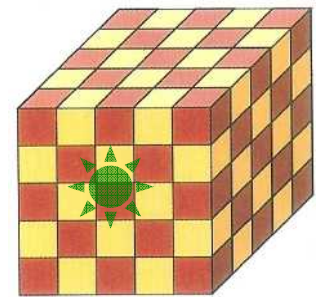
1D



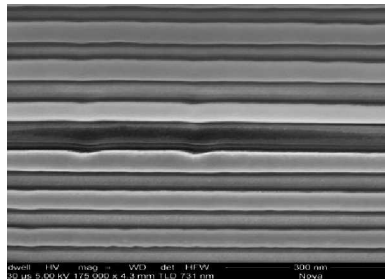
2D



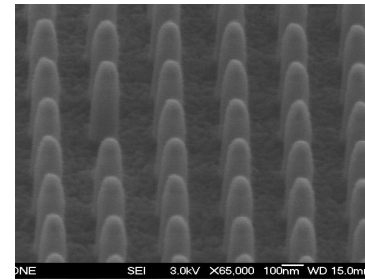
3D



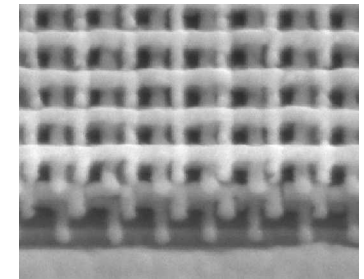
Modify emission behavior: Sources with novel and improved functionalities



HfO₂/SiO₂ DBR cavity



Array of TiO₂ rods



TiO₂ logpile PC

- High brightness/efficiency
- Tunable
- Directional, compact
- Anti-bunched
- Entangled

3D photonic crystal: density of states

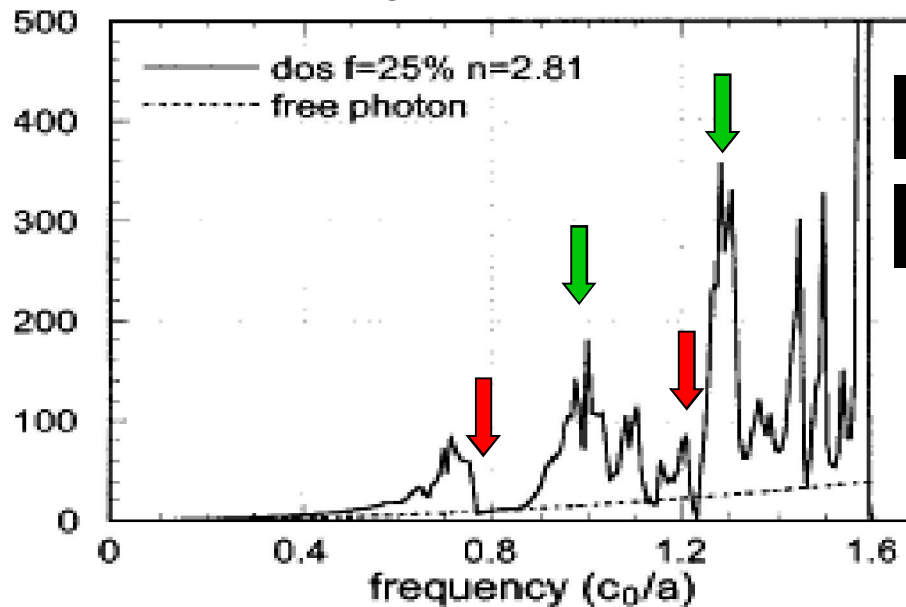
Radiative decay rate
(dipole in a PC at coordinate 'r')

$$\Gamma_{\text{rad}}(\mathbf{r}) = \frac{\pi \omega \mu^2}{3 \hbar \epsilon_0} N_{\text{rad}}(\mathbf{r}, \mathbf{d}, \omega)$$

**Local radiative
density of states
(LRDOS)**

$$N_{\text{rad}}(\mathbf{r}, \mathbf{d}, \omega) = \frac{1}{\epsilon(\mathbf{r})} \sum_{n,k} 2\omega \delta(\omega^2 - \omega_{n,k}^2) |\mathbf{d} \cdot \mathbf{A}_{n,k}(\mathbf{r})|^2$$
$$\mathbf{A}_{n,k}(\mathbf{r}) = (\nabla \times \mathbf{H}_{n,k}(\mathbf{r})) / (\sqrt{\epsilon(\mathbf{r})} i\omega_{n,k})$$

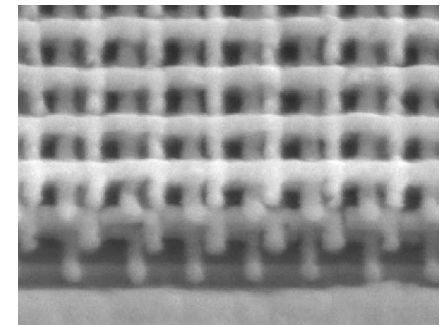
Photon Density of States in a 3D PC*



❖ **Enhancement**

❖ **Suppression**

3D photonic crystal

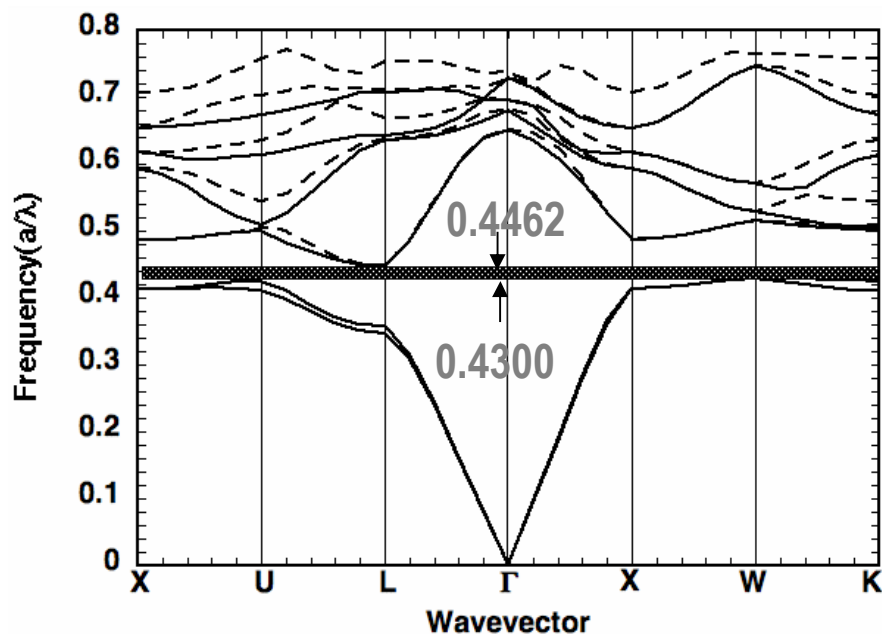


→ 3D PCs offers complete light control
→ Density of states is position dependent
→ Emitter placement inside PC is crucial

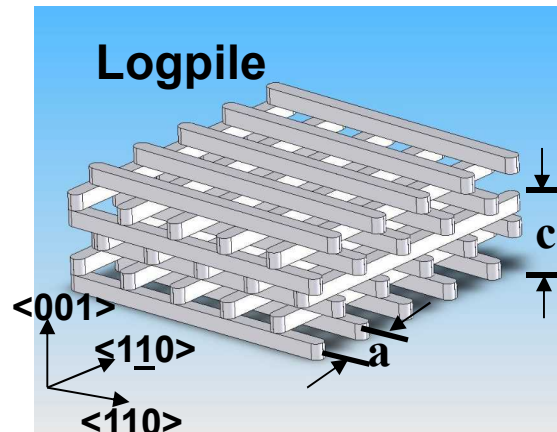
*T.Suzuki et. al., JOSA-B, **12**, 570 (1995)

3D Photonic Crystals: Logpile Structure

- Dielectrics at visible frequencies have lower refractive indices (2.0-2.7) than in the near-IR
- Inverse Opal not suitable for use in the visible
- Logpile geometry enables complete 3D gap with $n > 1.9^*$
- TiO_2 : Suitable for visible PC/ low loss high index (2.3-2.7)



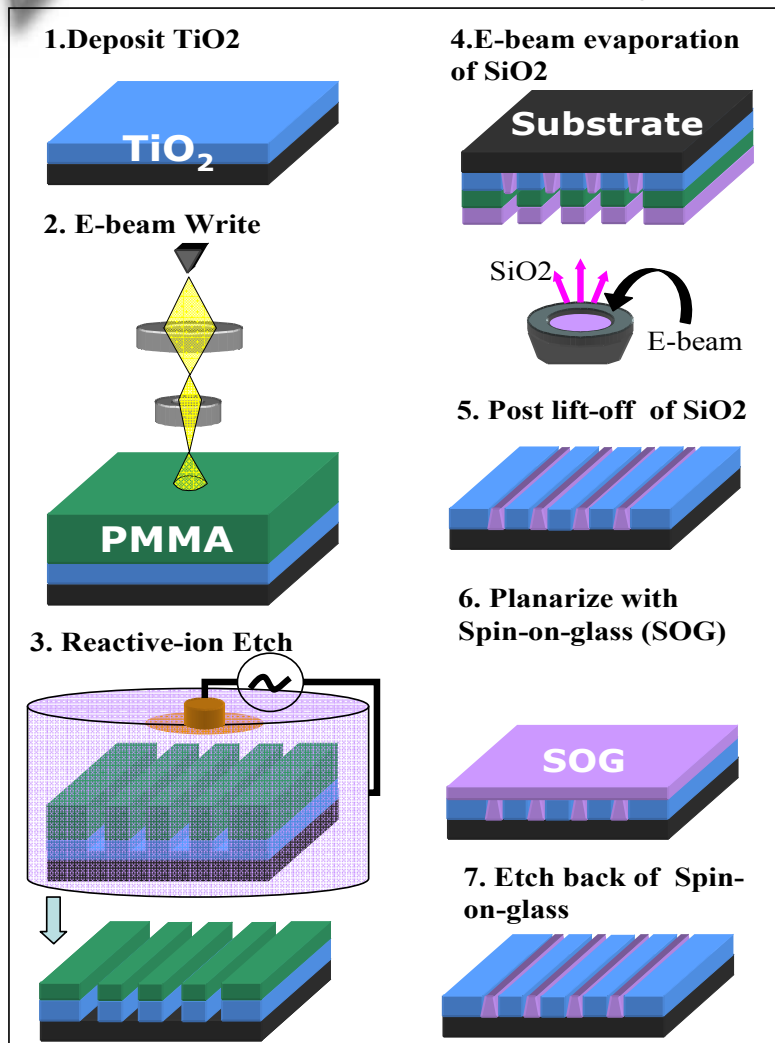
* K.M.Ho et.al. , Solid State Comm., **89** ,413(1994)



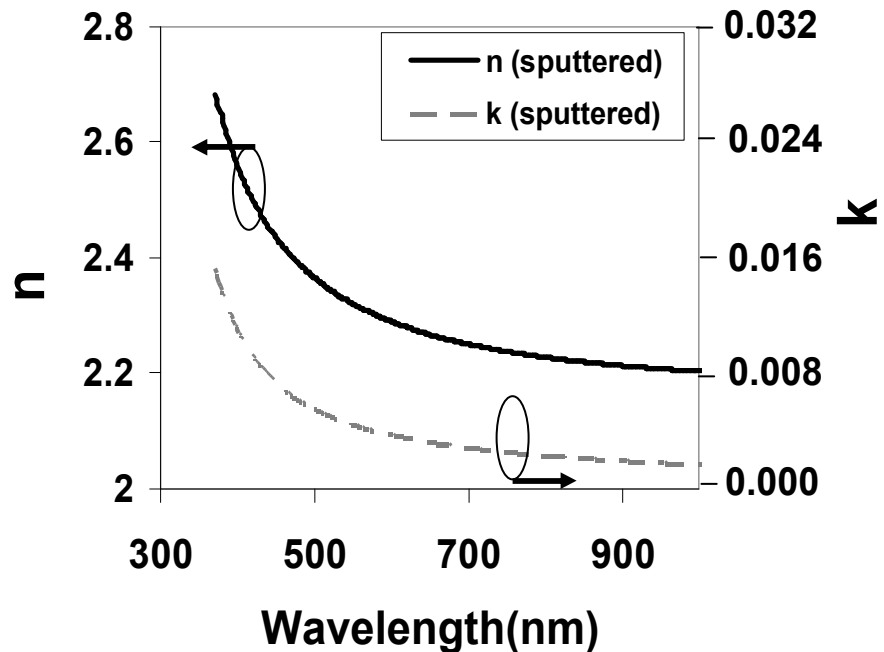
- 4% bandgap
- $\sim 25\text{nm } \delta\lambda$ at $\lambda \sim 600\text{nm}$

Logpile PC Fabrication: Sputtered TiO_2

Fabrication steps for one layer

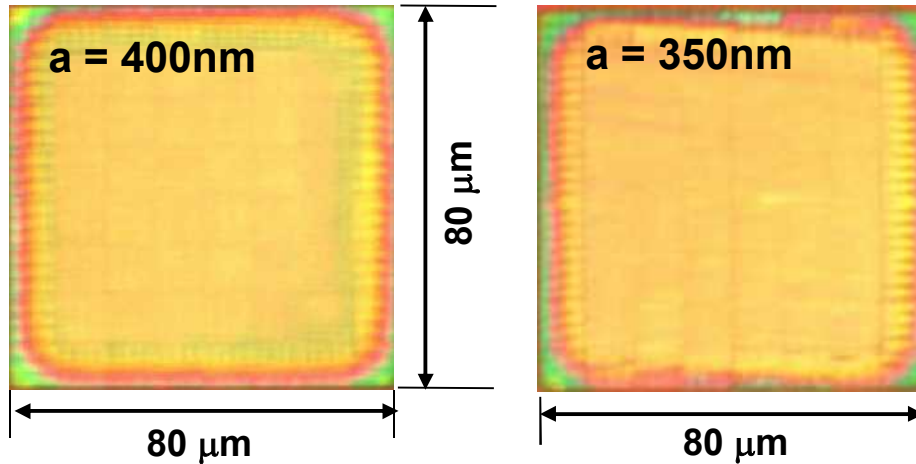


- Thicker e-beam resist (PMMA) is required due to poor etch selectivity of TiO_2
- Thicker PMMA results in poor dose control to obtain rod width uniformity between layers
- Reasonable index at visible wavelengths

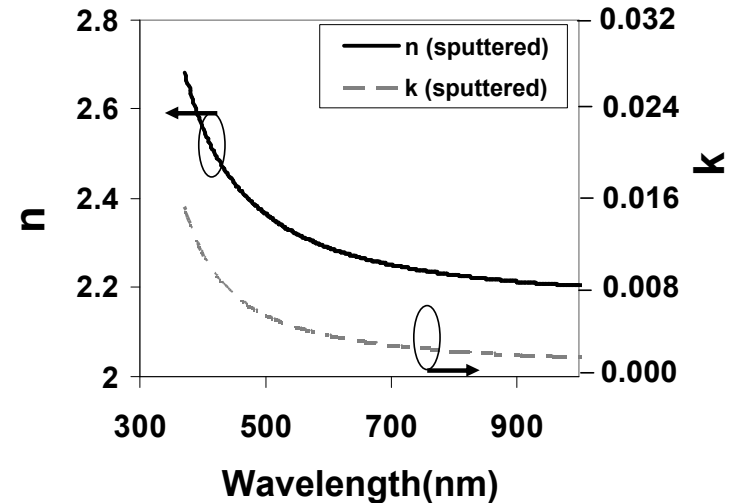


Visible TiO₂ Logpile 3D Photonic Crystals

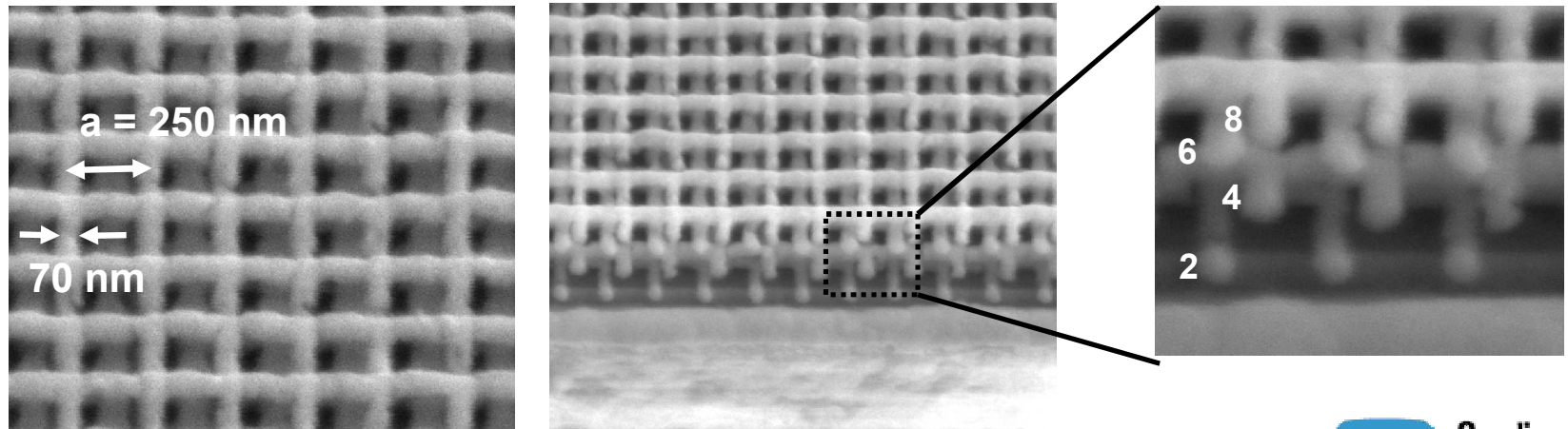
White light microscope images (5 layer sample)



TiO₂ index of refraction

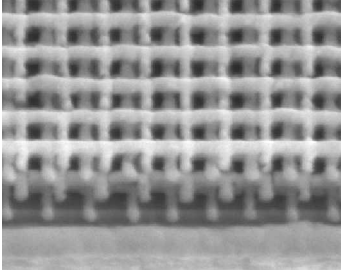


SEM images (9 layer sample)



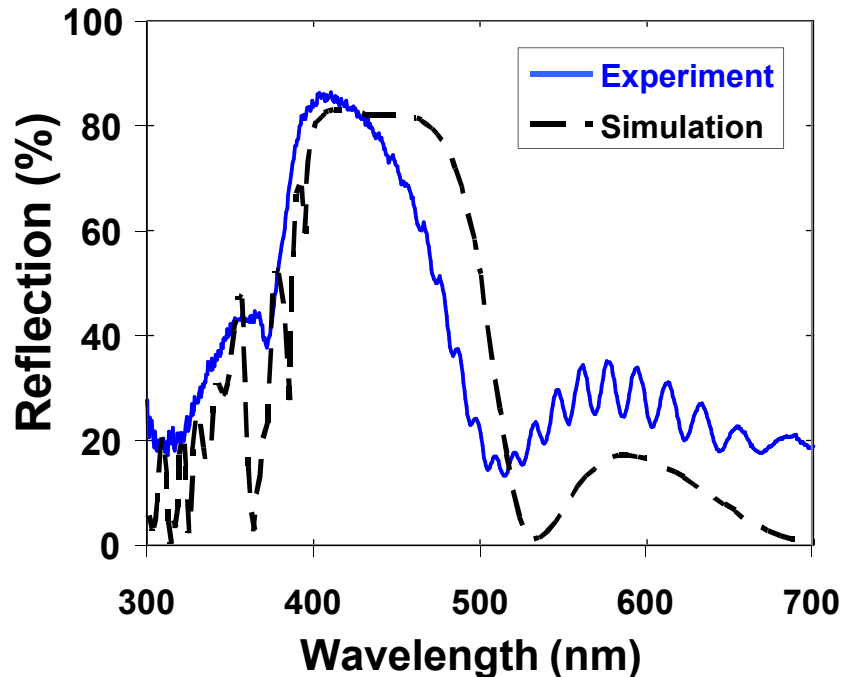
Reflectance from 9-Layer Visible TiO₂ Logpile

SEM - 9 layer logpile

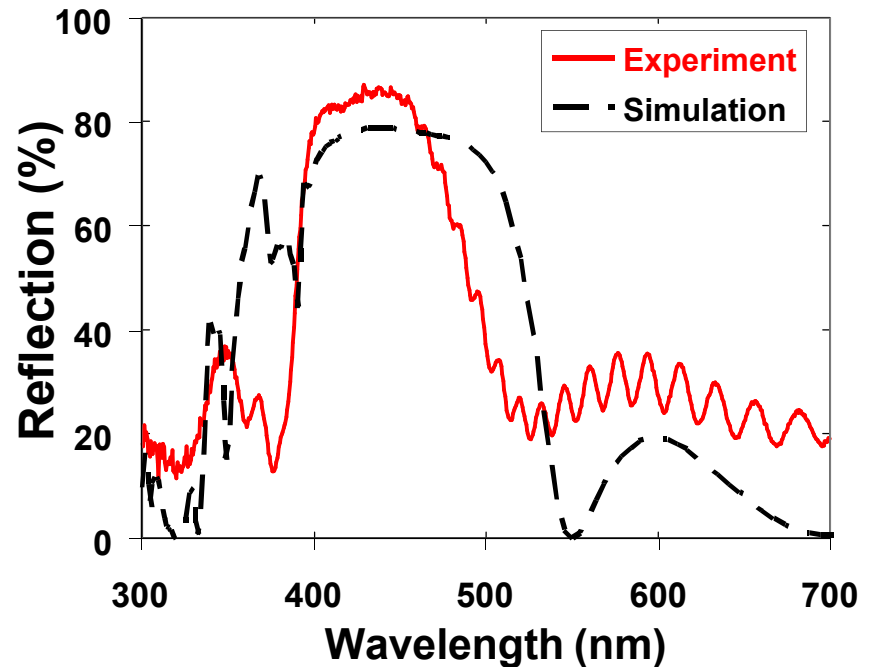


- Near normal incident reflection data
- Nine layer structure with lattice constant $a=250$ nm
- Bandgap extends from 400 to 500 nm
- Reflection greater than 80% $\rightarrow$ excellent morphology
- Demonstrates that TiO₂ PCs can be used at 400 nm

Reflection- Parallel Polarization



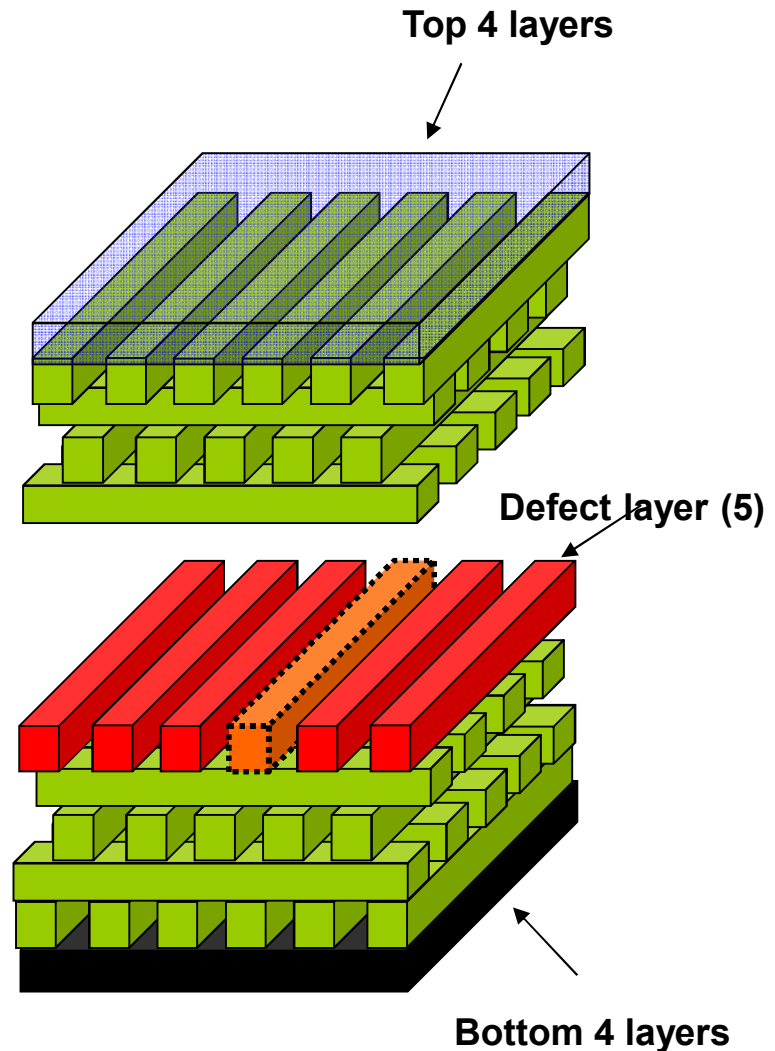
Reflection- Perpendicular Polarization



3D photonic crystal 'air defect' microcavity

Geometry: 9 layer structure with microcavity defect in the 5th layer

- Portions of rods removed to create 'air' defect cavities
- Fabricate bottom 5 layers first and then the top 4 layer separately on a transparent substrate (sapphire)
- Enables introduction of light emitters (e.g. QDs) post fabrication using chemical functionalization (already developed)
- Evaluate cavity modes: resonance frequency, Q factor
- **Small modes volumes and high Q are desired**



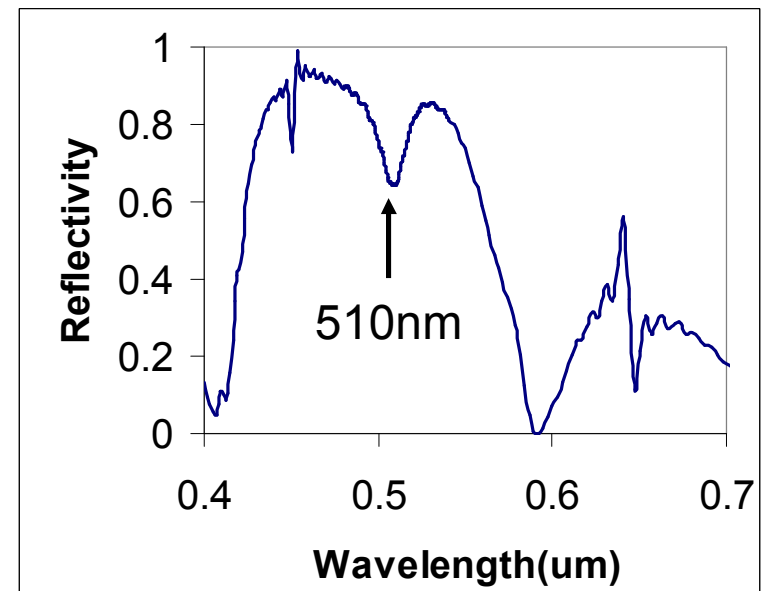
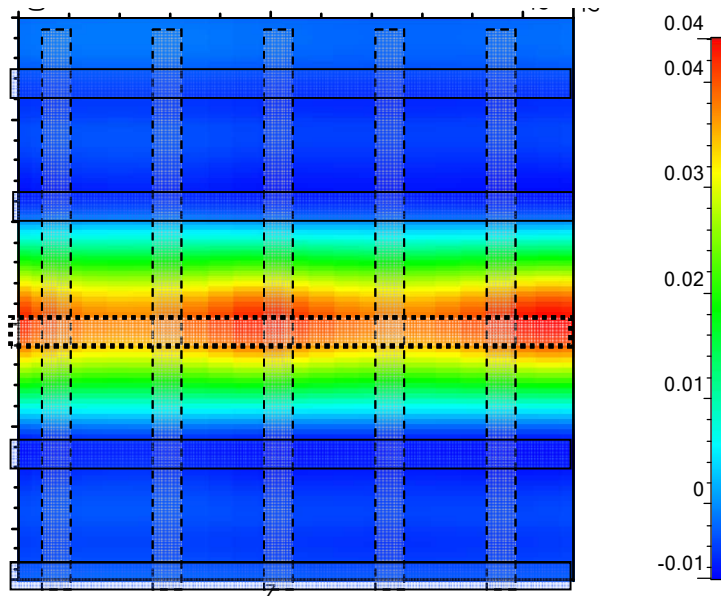
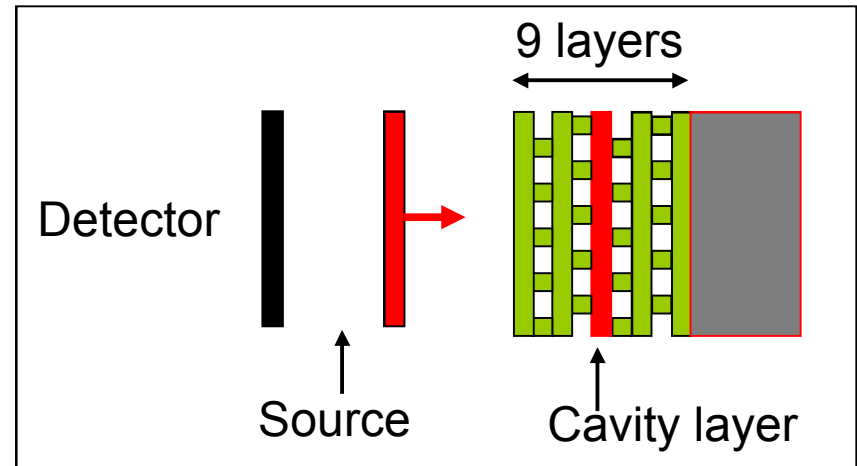
FDTD modeling of microcavity reflectance

FDTD conditions:

- Supercell: 5 unit cells
- Cavity defect periodic with 5 unit cells
- Periodic boundary conditions in the transverse
- Gaussian source

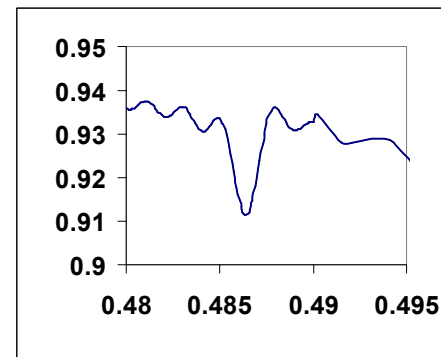
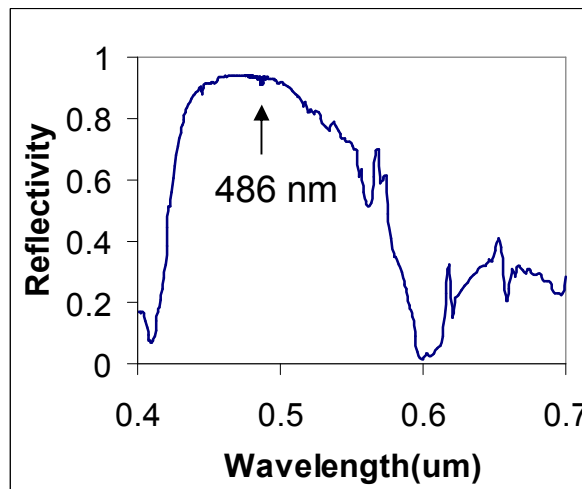
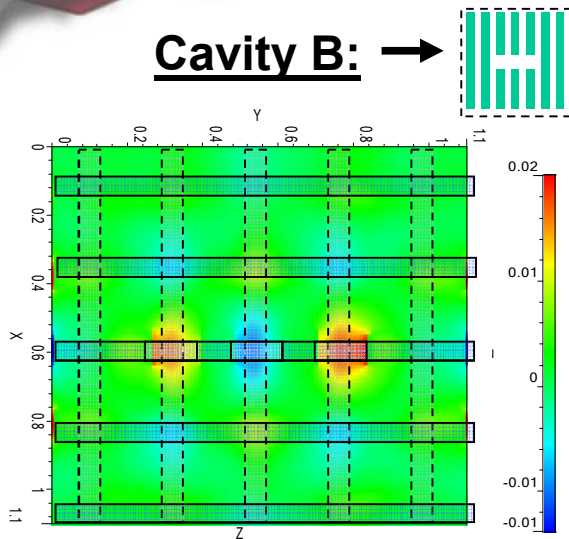
Cavity A: Every 5th rod removed

- Q factor ~ 30
- Mode volume : $2 \cdot (\lambda/n)^3$



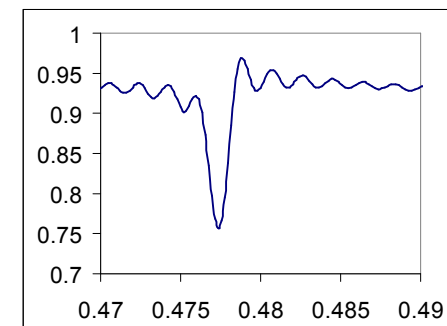
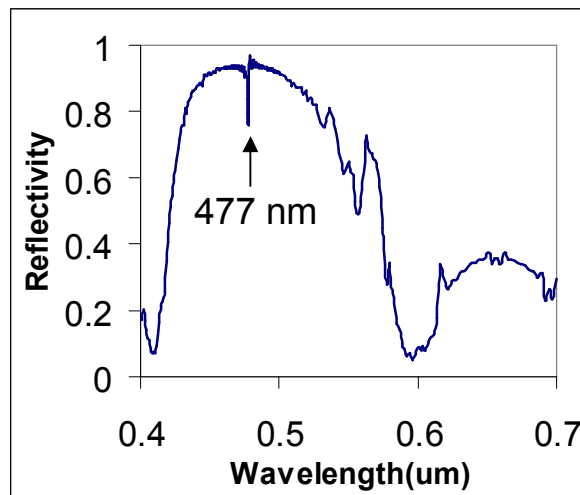
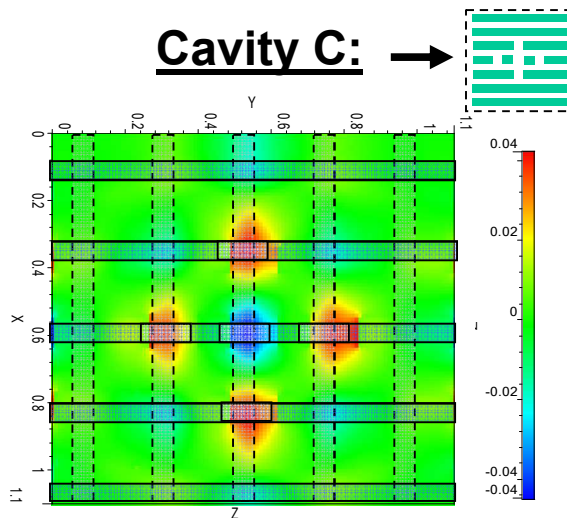
FDTD modeling of microcavity reflectance

Cavity B: →



- $Q \sim 250$
- $MV : 0.25(\lambda/n)^3$

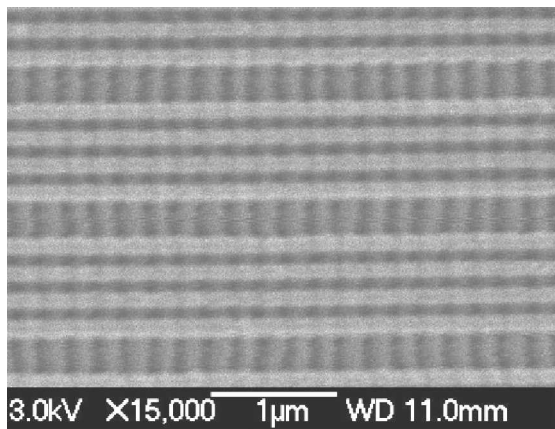
Cavity C: →



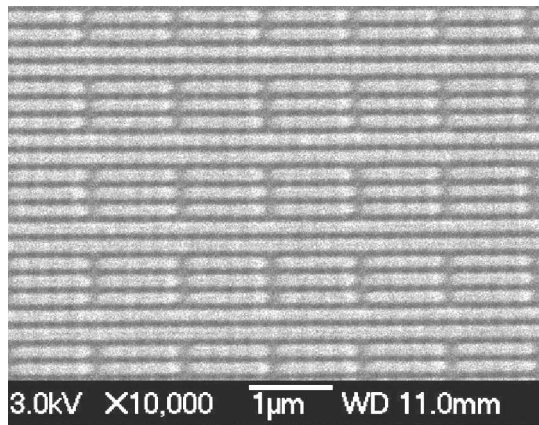
- $Q \sim 300$
- $MV : 0.42(\lambda/n)^3$

Fabricated TiO_2 Photonic Crystal Cavities

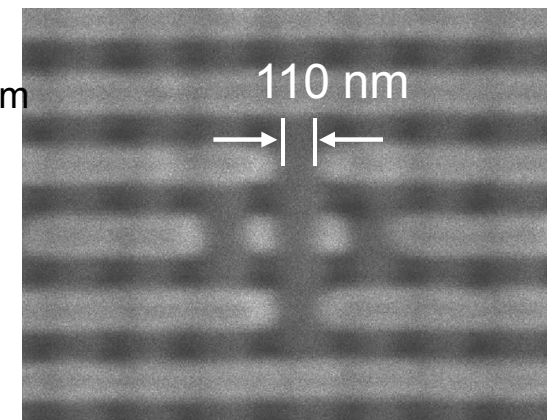
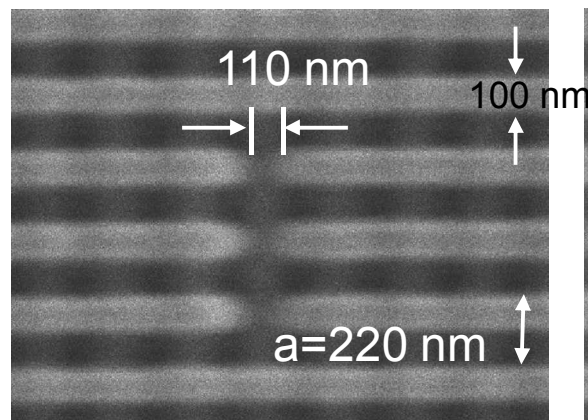
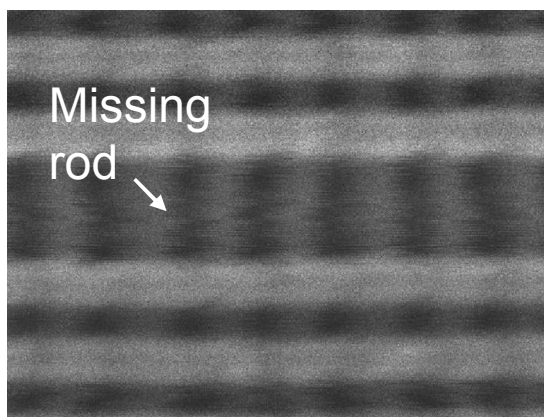
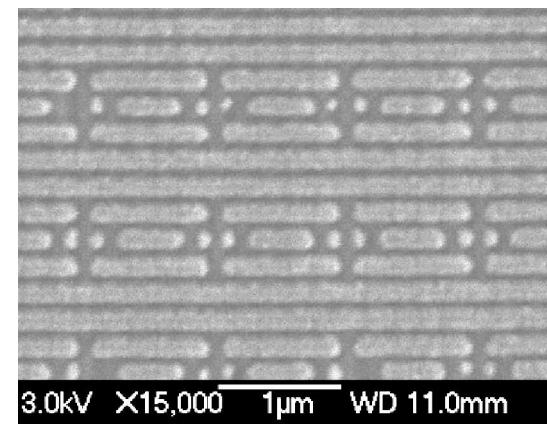
Cavity A



Cavity B

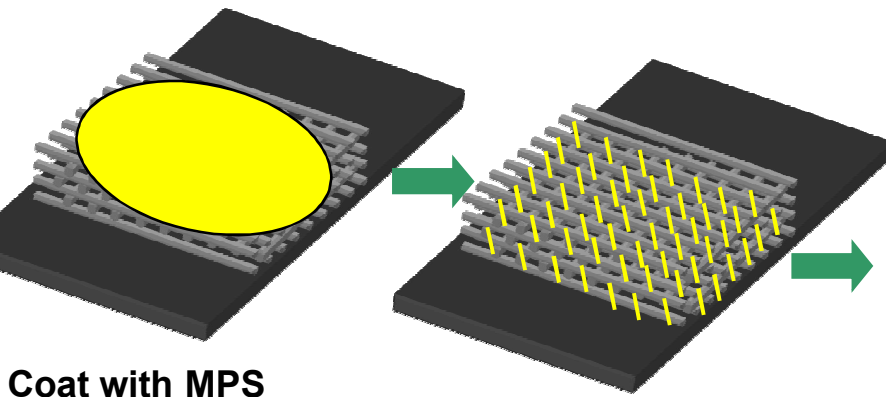


Cavity C

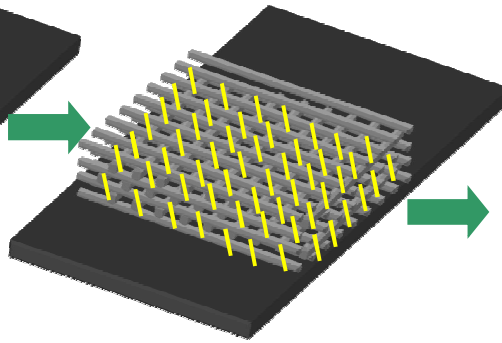


Self-assembled Monolayer of CdSe on TiO₂

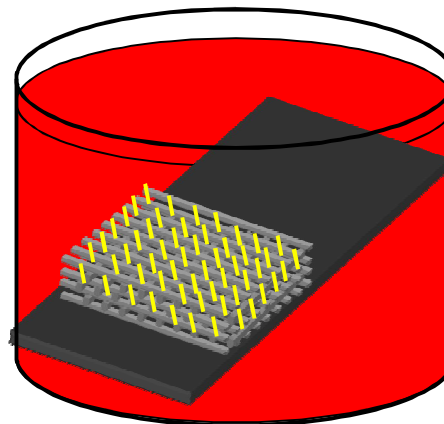
1. Coat TiO₂ logpile with neat 3-mercaptopropyltrimethoxysilane (70 °C, 3 min)
2. Rinse with chloroform
3. Bake logpile on hot plate to form linkage (120°C, 30 min)
4. Place TiO₂ logpile in TOPO-capped CdSe in toluene (RT, 1 hr)



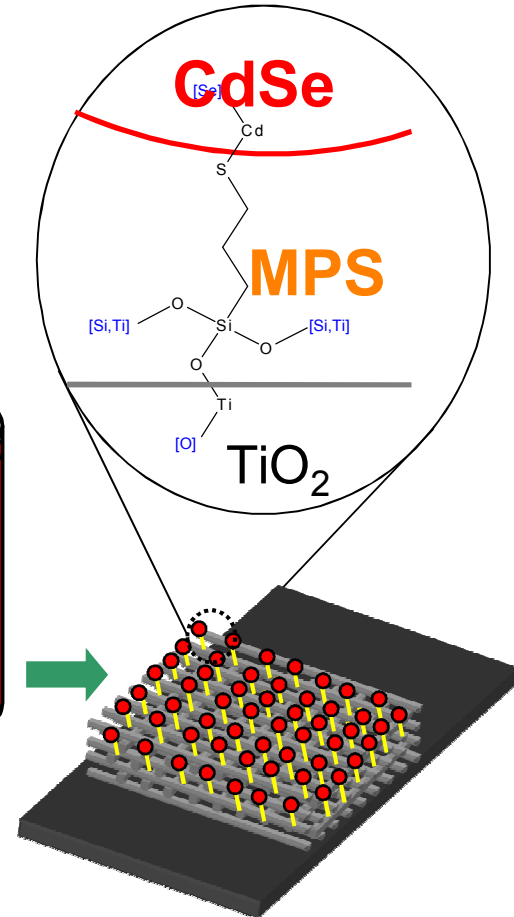
Coat with MPS



Rinse off MPS
Bake to form self-assembled monolayer(SAM)



Submerge in CdSe suspension to exchange ligands



Rinse off unattached CdSe

P. Guyot-Sionnest and C. Wang, J. Phys. Chem. B, 107, 7355 (2003)
J. Pacifico, D. Gomez, and P. Mulvaney, Adv. Mater. 17, 415 (2005)

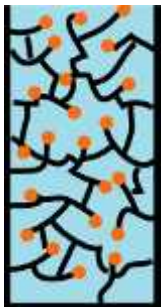


Evident QDs

Improving QD uniformity using Silica Aerogel

- High surface to volume ratio of silica aerogel
 - Increased surface area for QD attachment
 - Higher probability of overlap of the QD emission with PC LDOS
 - Potentially minimal disturbance of the bandstructure
- Sol-gel approach requiring no special drying procedure
 - Capping agent halts condensation, allows spring-back after drying
- **Successfully incorporated QDs into 3D logpile structures**

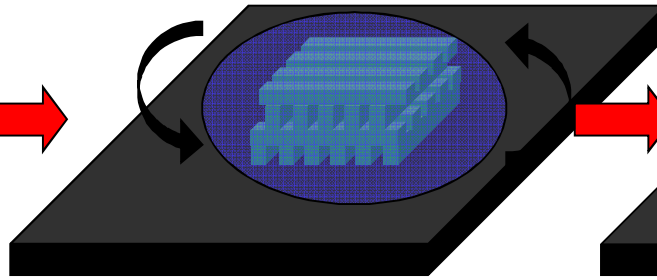
Age and
cap gel



Disperse by
sonication

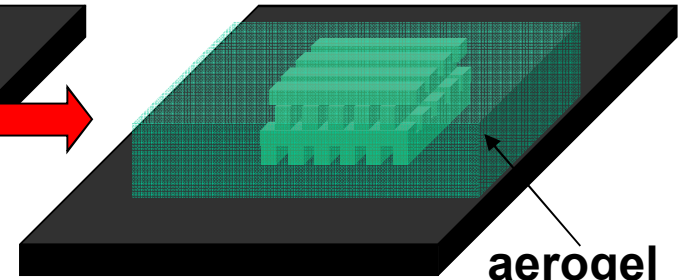


Spin coat



Logpile PC

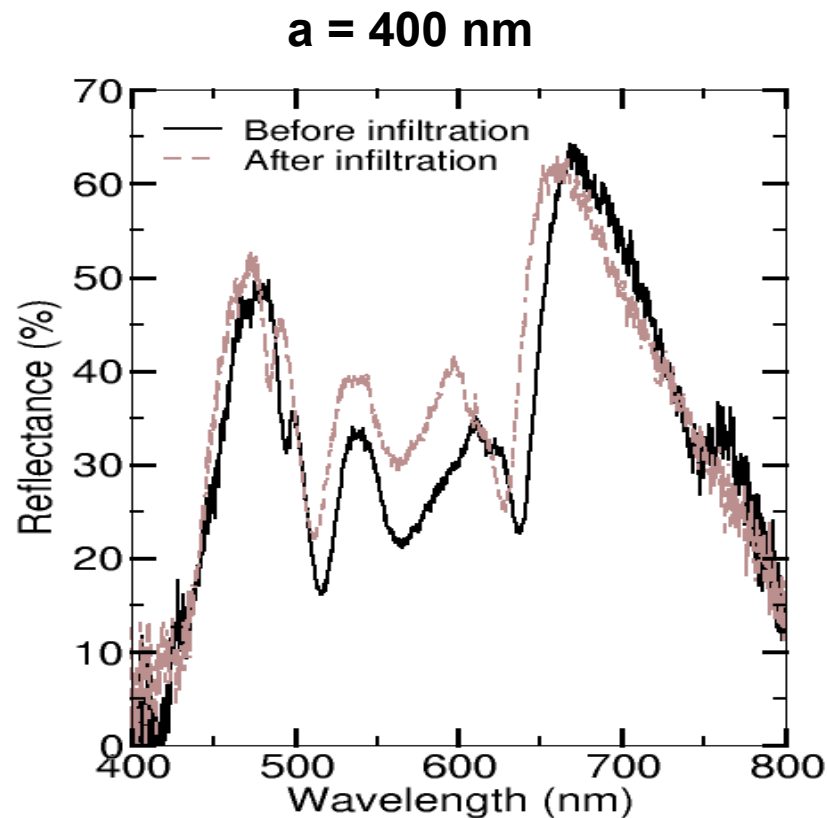
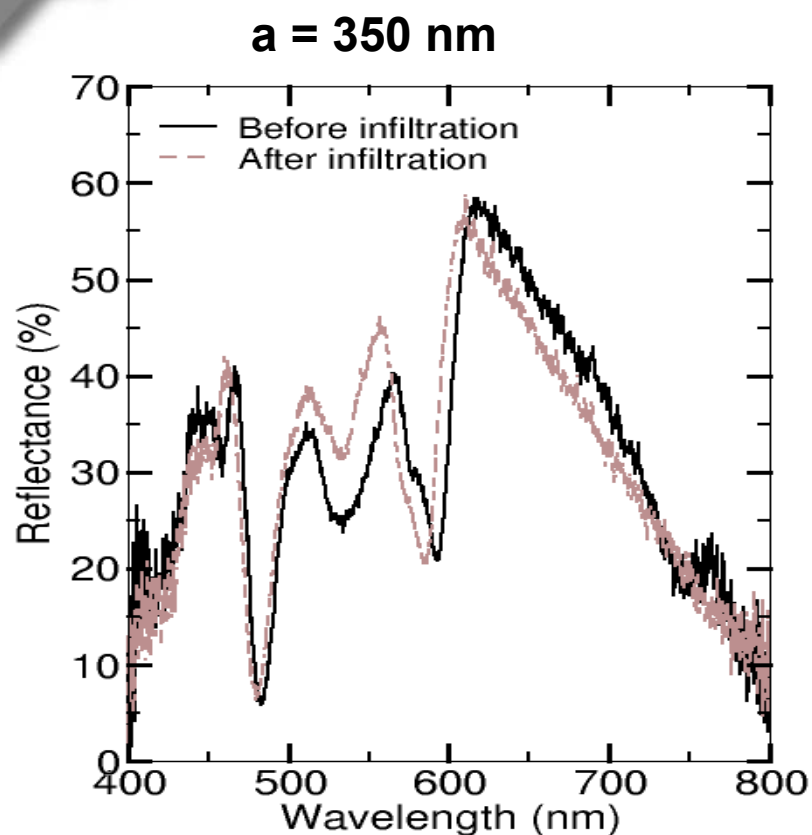
Dry at RT



aerogel

S. S. Prakash et al., Nature 374, 439 (1995)

Effect On Bandgap Due To Aerogel + CdSe Infiltration



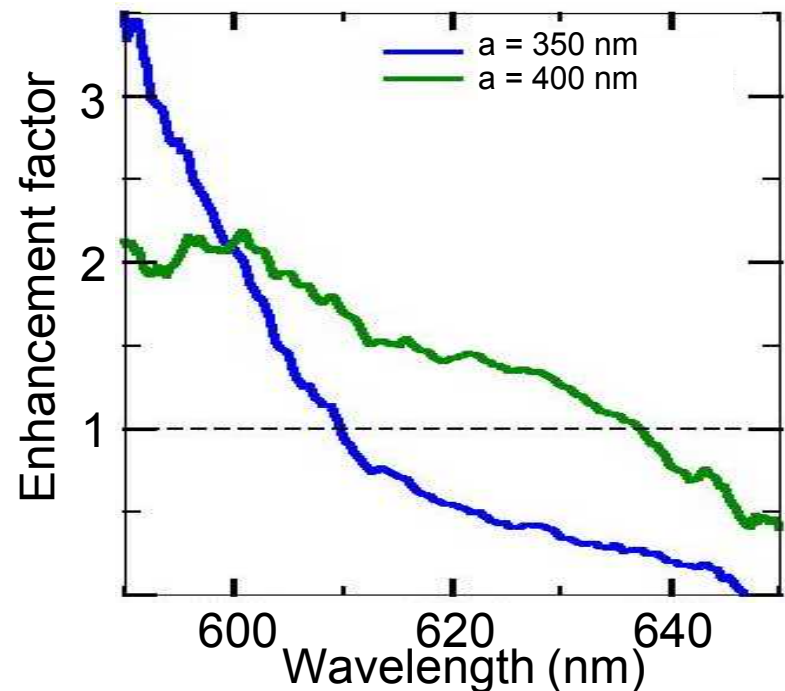
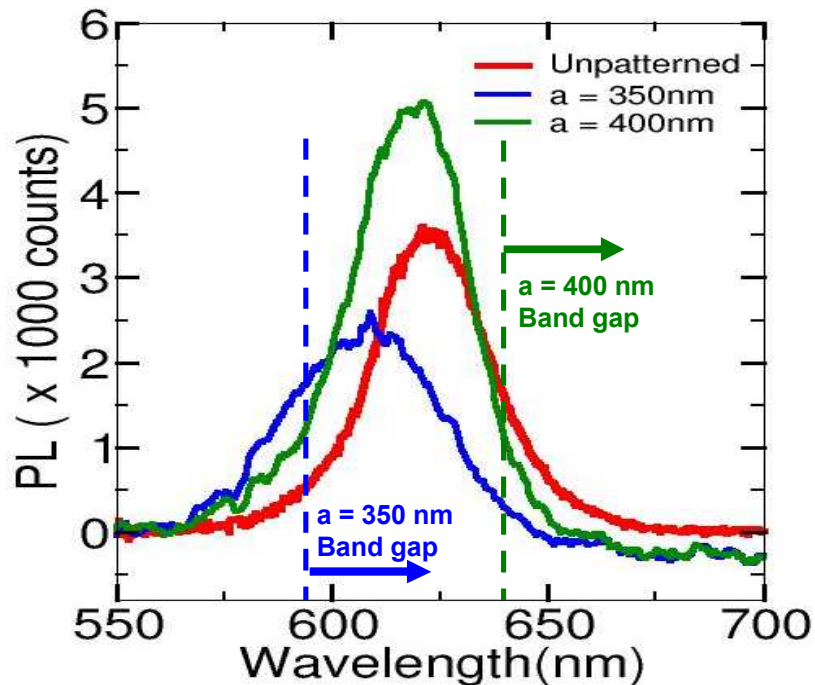
For rod filling fraction $f \sim 0.4 \pm 0.05$; $n_{\text{aero}} \sim 1.1 \pm 0.05$

Minimal effect on the bandgap!

G. Subramania et al., Appl. Phys. Lett. **95**, 151101 (2009).

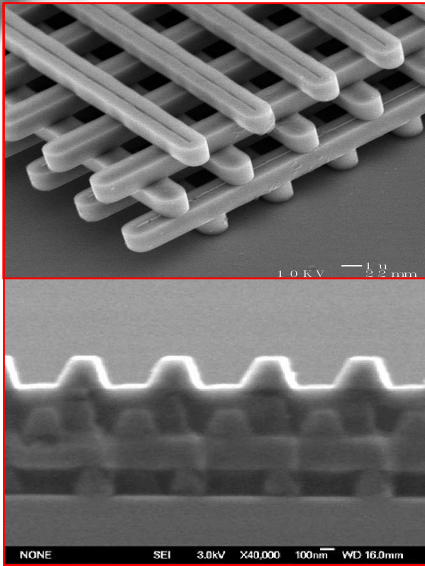
PL Response of CdSe QDs Inside the PC

- Incorporated CdSe quantum dots into TiO_2 3D logpile structures
- Developed Aerogel + quantum dot infiltration process
- PL is enhanced for 400 nm lattice constant (outside band gap)
- PL is suppressed for 350 nm lattice constant (inside band gap)
- 3D photonic crystal is effective at controlling photon emission

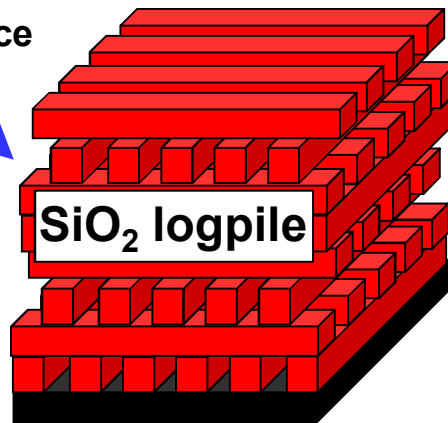


G. Subramania et al., Appl. Phys. Lett. **95**, 151101 (2009).

Fabrication of all GaN Vis-UV Logpile PC

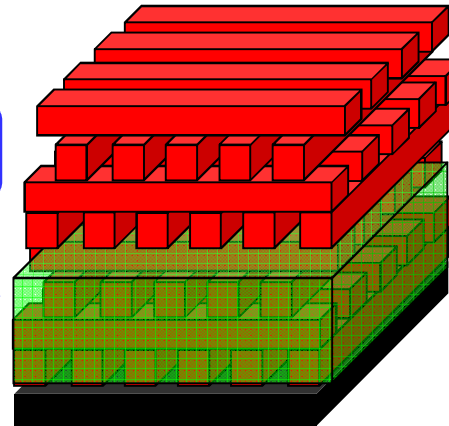


1. Fabricate Si logpile with SiO₂ background still in place



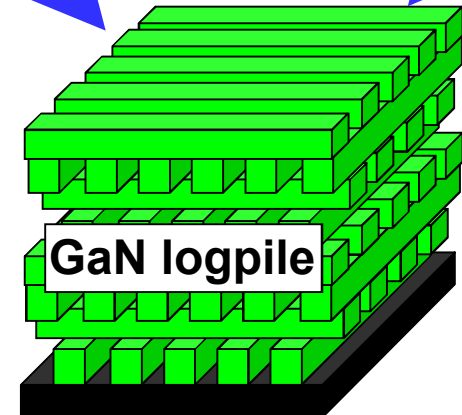
2. Etch out Si using KOH leaving SiO₂ skeleton in place

GaN grows uniformly throughout structure



3. Grow GaN by MOCVD

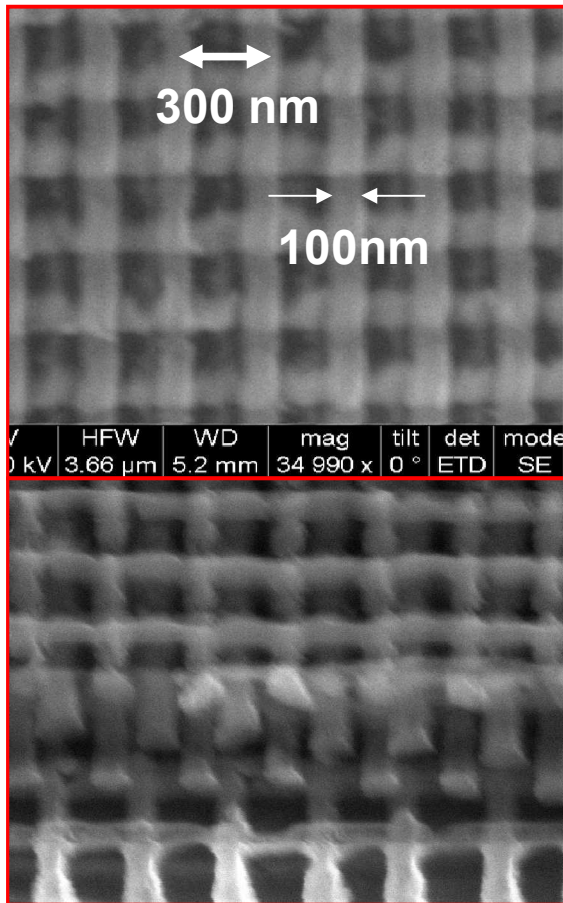
Transparent to 365nm
Index ~ 2.5



4. Remove SiO₂ template to leave behind GaN logpile

All GaN Vis-UV Logpile Photonic Crystal

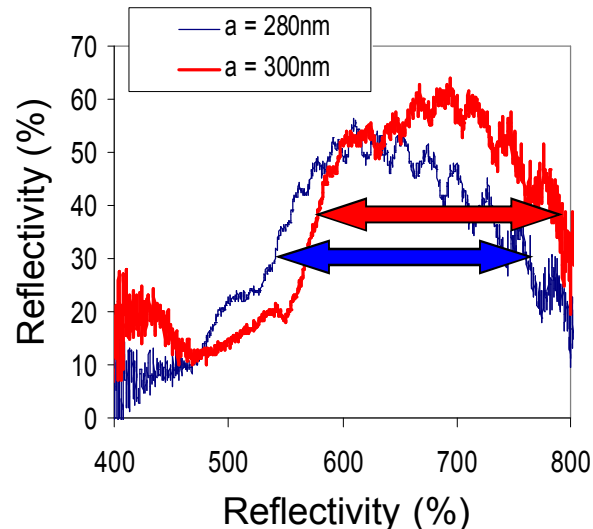
SEM images of GaN PC



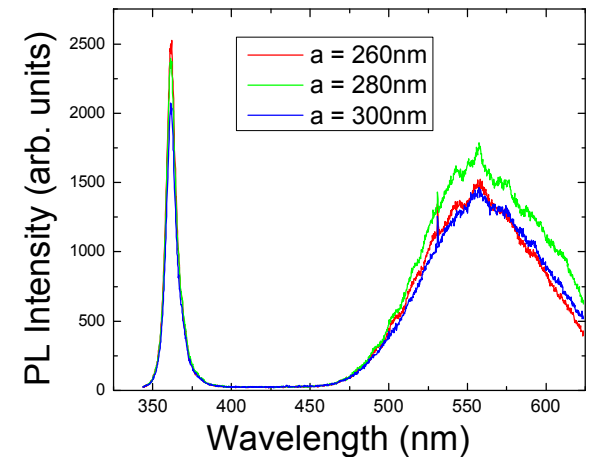
Implications of GaN logpile PC:

- Demonstrated all GaN 3D PC structure
- Important step forward for visible PCs
- Extremely good transparency across entire visible spectrum and into UV
- Potential to demonstrate shortest 3D PC
- Incorporate InGaN emitters, n-type and p-type
- Clear path to an electrically-injected 3D photonic crystal light source

Reflectivity from GaN PC sample

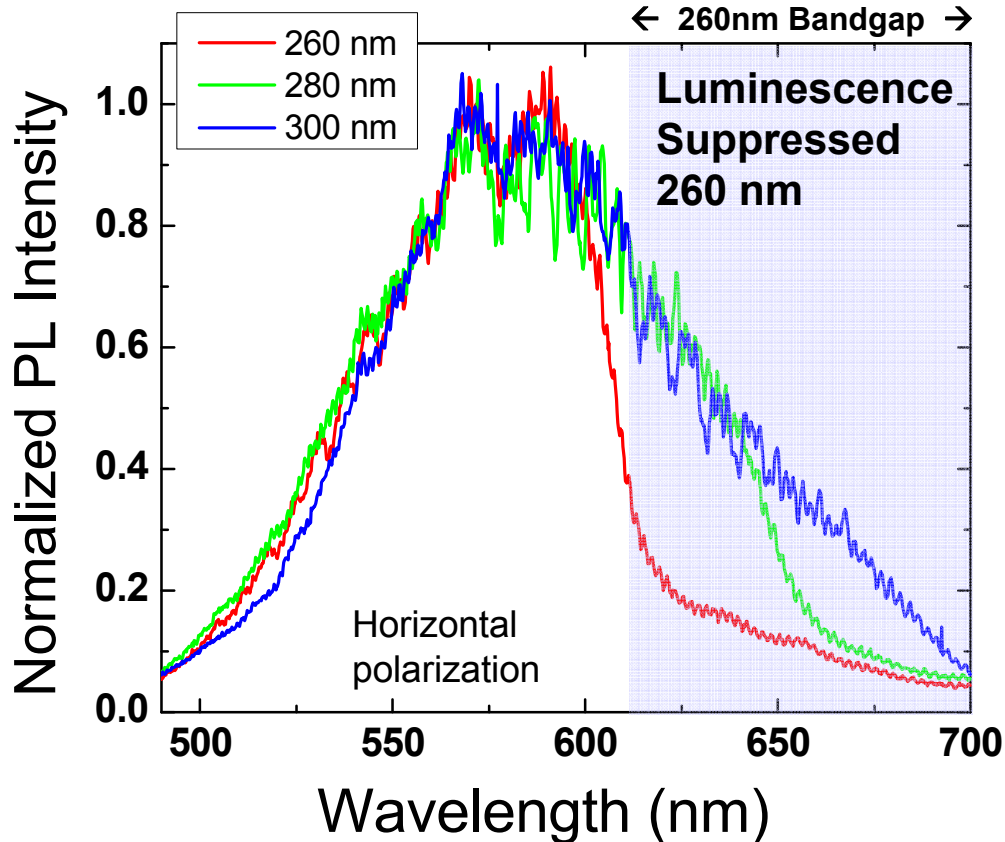


PL from GaN PC sample

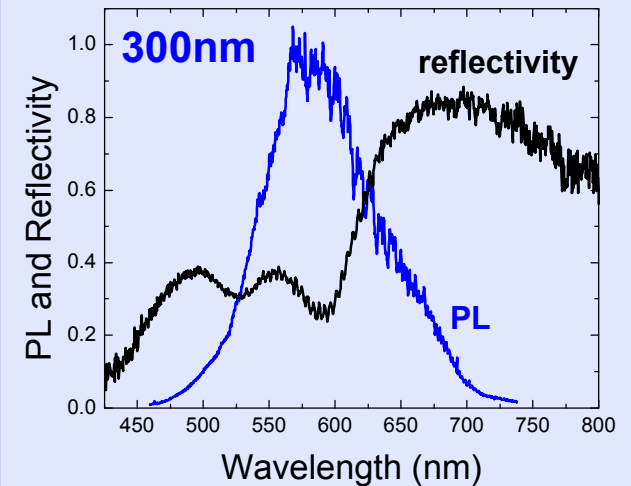
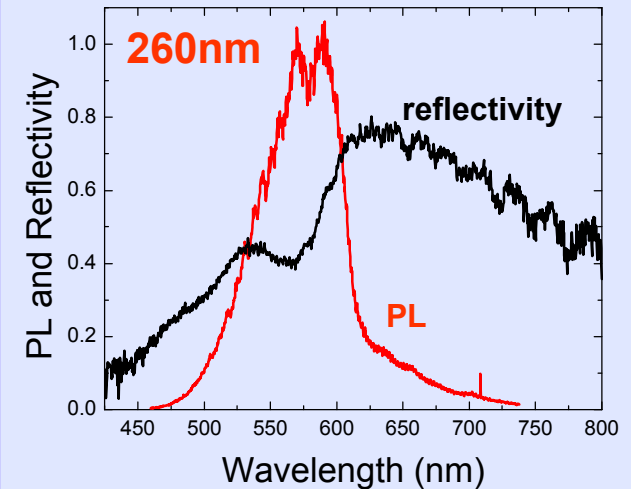


TIPL data from 5 layer GaN logpile: oxide removed

- Focus on GaN yellow-band emission (570nm)
- PL change only for horizontal polarization
- 5 layer logpile with $a = 260\text{nm}, 280\text{nm}, 300\text{nm}$
- Largest effect for 260 nm lattice constant
- **PL suppressed inside band gap region**

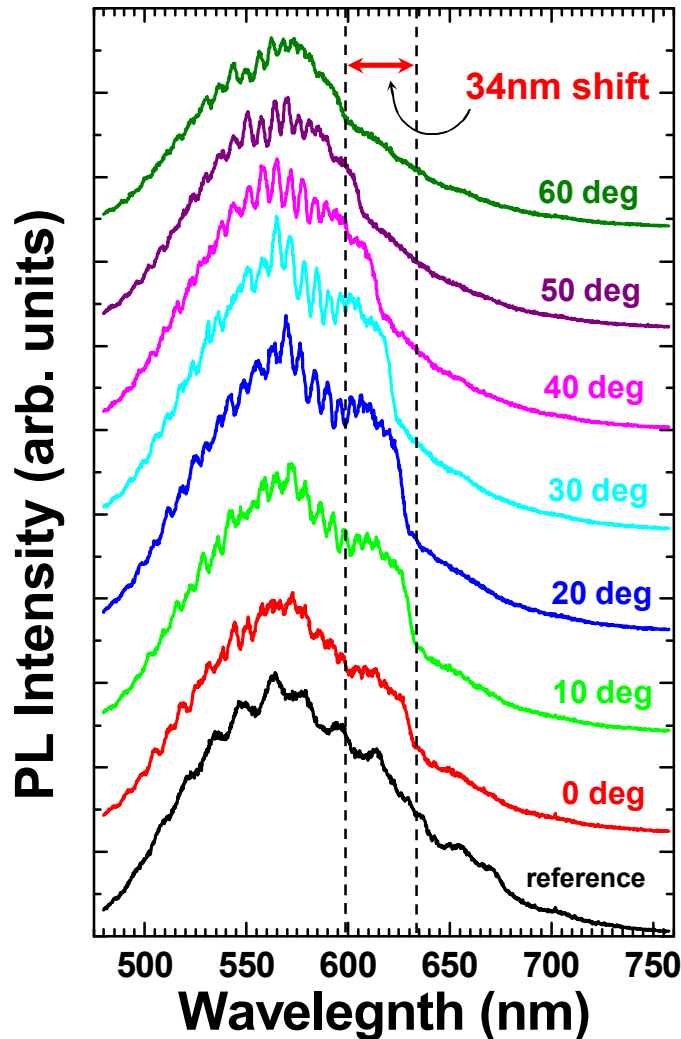


PL vs. Reflectivity

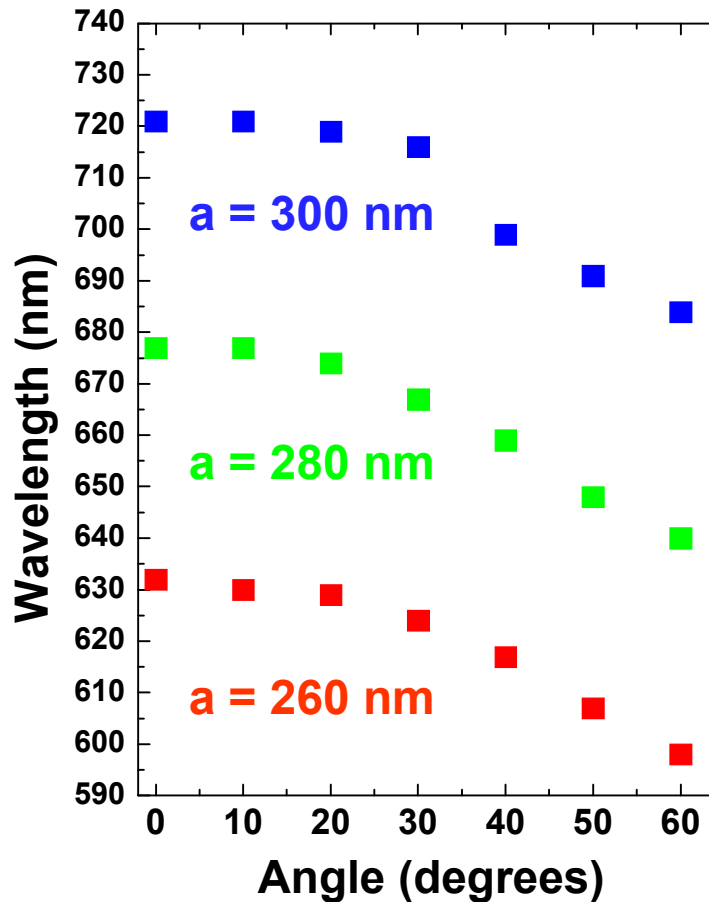


Angle dependent TIPL data from 5 layer GaN logpile: oxide removed

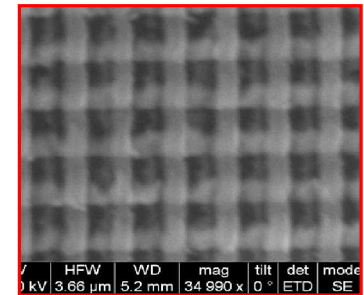
260nm lattice constant



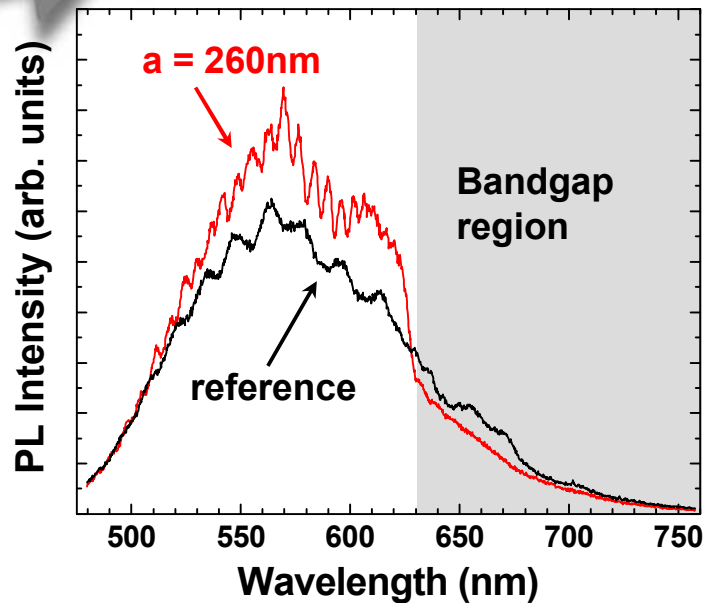
- Collect PL into a 2 degree solid angle
- Horizontal polarization (TM) shows bigger effect
- Band edge shifts with angle (~ 35 nm shift)
- Gives further evidence for GaN emission modification
- Need to compare to angle-dependent reflectivity



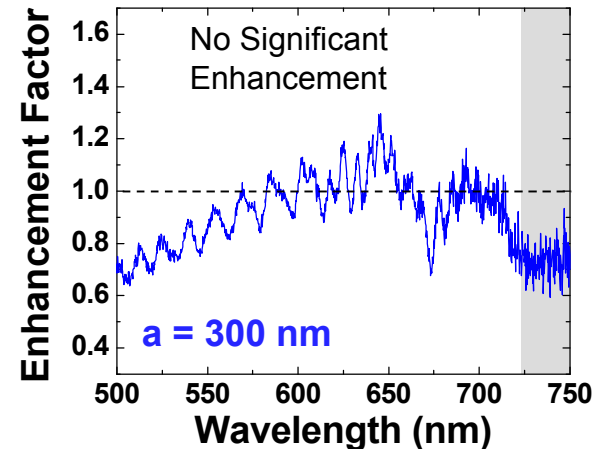
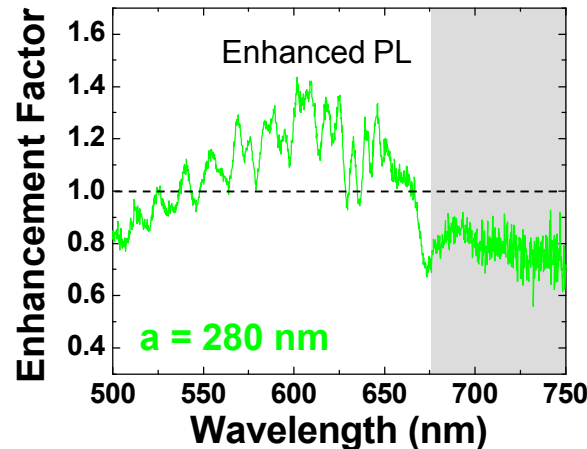
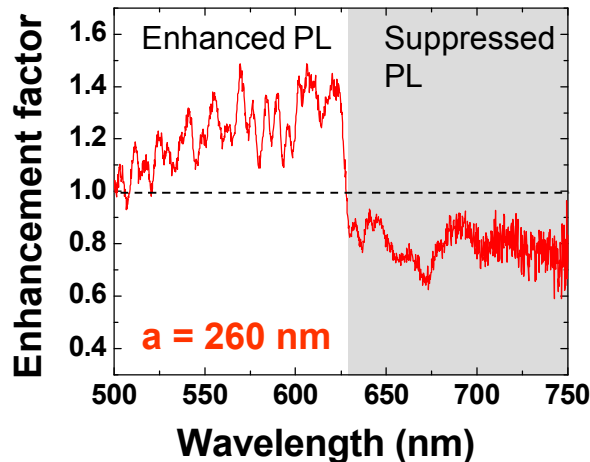
GaN 3D Logpile



Angle dependent TIPL data from 5 layer GaN logpile: oxide removed

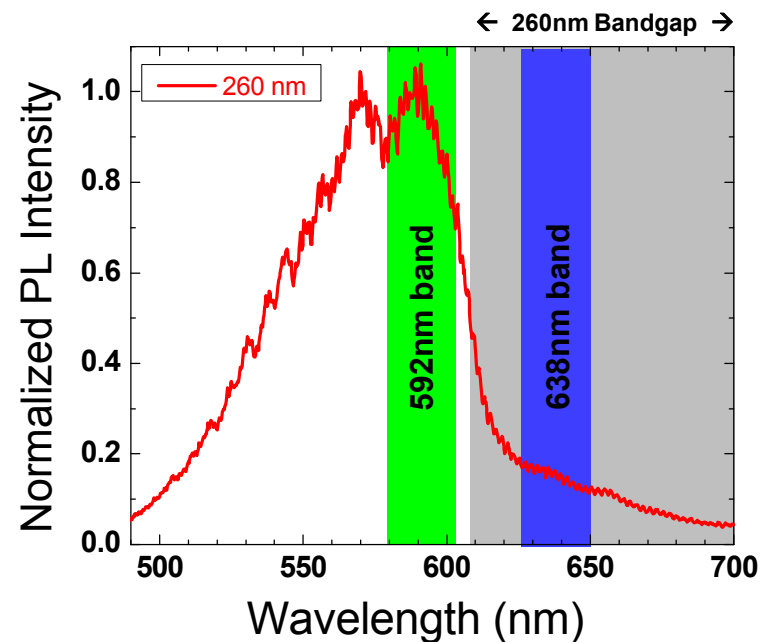
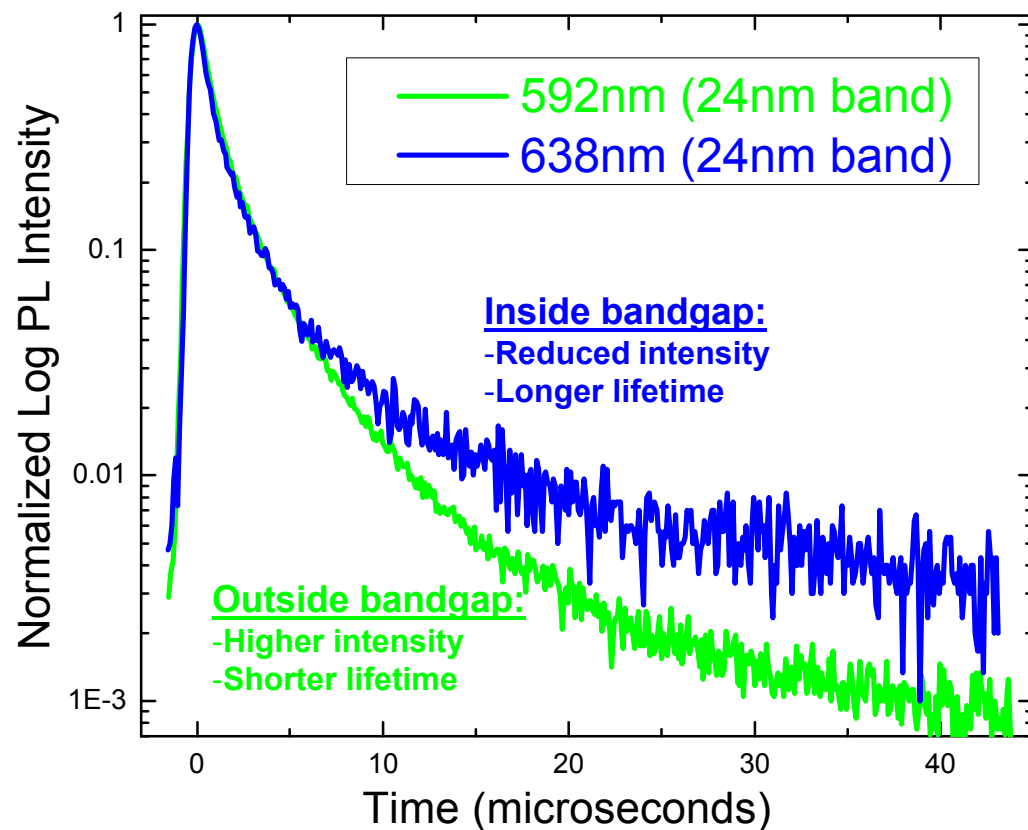


- Intensity comparison shows both enhanced and suppressed emission
- Reference curve is a representative GaN yellow band peak with characteristic lineshape
- Data shown for emission 20 degrees w.r.t. normal
- Horizontal polarization (TM) shows larger effect
- Emission enhancement as large as 1.4 X
- 20% reduction in PL intensity inside bandgap
- No significant effect for 300nm lattice constant



TRPL data from 5 layer GaN logpile: oxide removed

- Focus on 260nm lattice constant sample
- Small lifetime change for horizontal polarization only
- 100 fs pump at 340nm, streak camera with 15ps resolution
- **Longer lifetime and reduced intensity inside bandgap region**
- **Shows PL suppression is more than a passive effect**
- Larger change expected for emitters fully inside PC structure

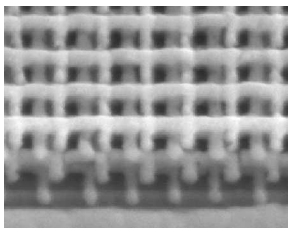


Summary

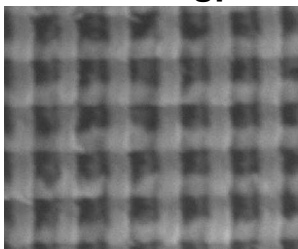
Accomplishments:

- Developed a method of fabricating 3D logpile photonic crystal structures made from TiO_2 for use in the visible.
- Incorporated quantum dot emitters in photonic crystal cavities and investigated luminescence properties.
- Demonstrated changes to luminescence intensity for TiO_2 3D logpile structures.
- Developed a new method to fabricate UV/visible 3D photonic crystal structure made totally of GaN material.
- Demonstrated changes to luminescence intensity and lifetime for GaN 3D logpile structures.
- Demonstrated control of light emission via altered photonic density of states.

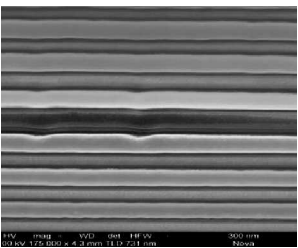
TiO_2 3D logpile



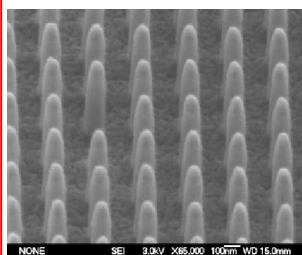
GaN 3D logpile



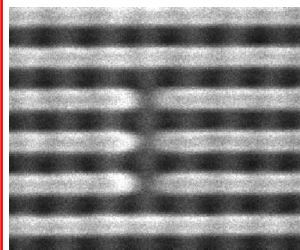
1D GaN cavity



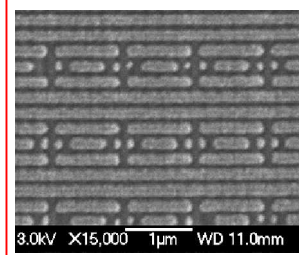
TiO_2 post array



Defect cavities



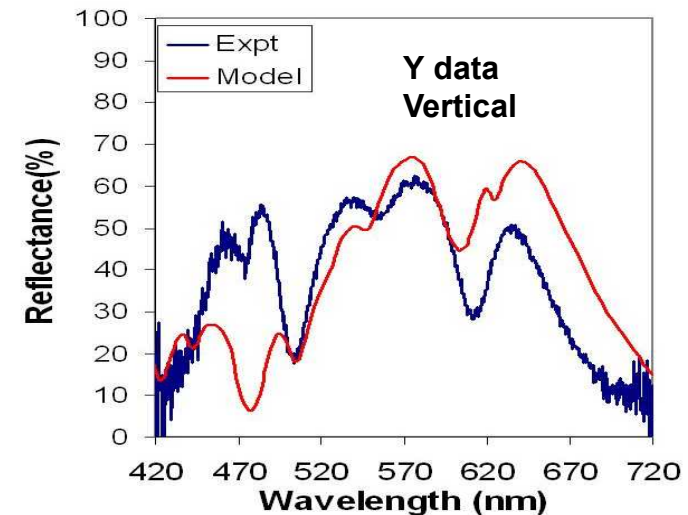
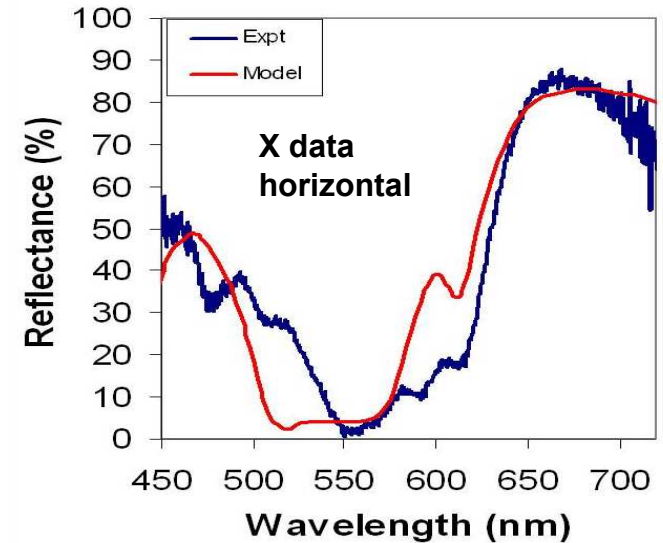
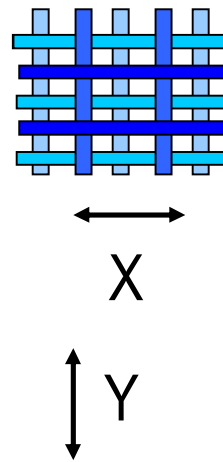
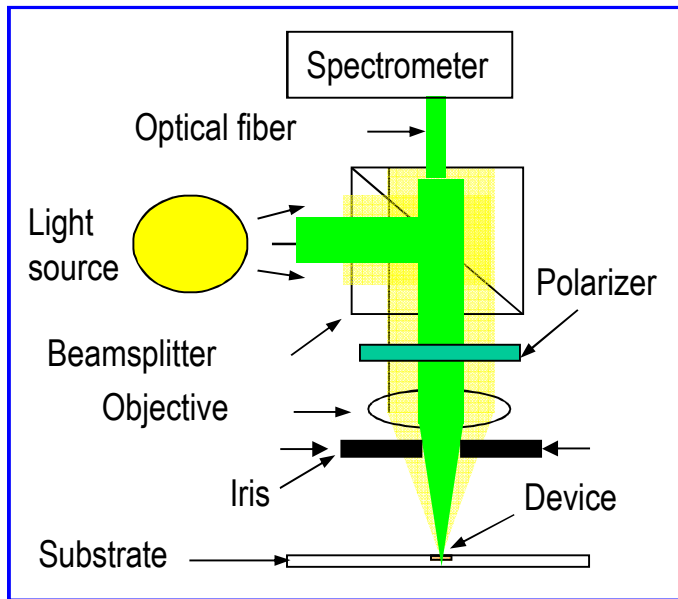
Defect cavities





Extra Slides →

Reflectance Response: Near Normal Incidence



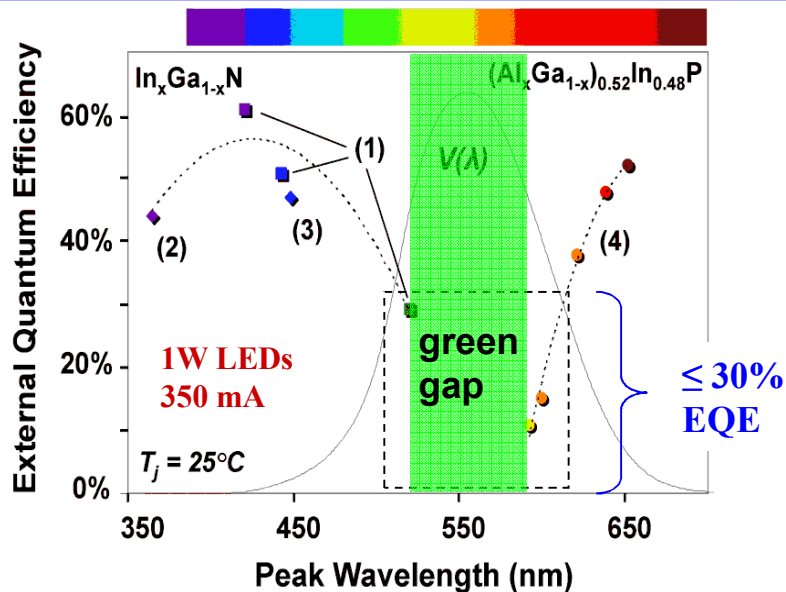
- 5 layer sample with $a = 400$ nm
- Entrance aperture at objective to reduce NA
- 'X' polar spectrum different from 'Y' polar
- Surface termination
- Incomplete unit cell for Y polar

Impact of 3D photonic crystal research

Example Application Area:

→ High efficiency lighting (SSL)

- Efficiency gap between nitrides and phosphides (green gap)
- Utilize changes to photonic density of states to increase efficiency
- Increase radiative rate to better compete with non-radiative



Significance of Results

- Advance our understanding of interaction between semiconductor emitters and 3D photonic crystals.
- Develop new fabrication methods for visible 3D photonic crystals.
- Pave the way for investigation of exciting new areas of physics research:
 - Polariton dynamics, strong coupling
 - Solid state Bose-Einstein condensation
- Enable the development of advanced photon sources for applications such as optical and quantum computing.
- Control photon emission processes at an new and unprecedented level.
- Create solid state light sources with new functionality:
 - High Brightness/Efficiency
 - Single/Entangled Photon Sources
 - Directional, Compact
 - Anti-bunched Photons